

## **INDIAN SCHOOL DARSAIT**



## DEPARTMENT OF CHEMISTRY

| Sub | ject: Chemistry Topic: p-Block Elem   | ents Date of Worksheet:. 79.2  | 2018              |  |  |  |
|-----|---|--|-------------------|--|--|--|
| Res | ource Person: SREEKALA M  | Date of Submission:  |                   |  |  |  |
| Nar | me of the Student: Class &D   | vivision: XII Roll Number:   |                   |  |  |  |
| 1.  | Which is a stronger acid in aqueous solution, H   | Cl or HI? And why?   | 1                 |  |  |  |
| 2.  | Which one has higher electron gain enthalpy wi  | th negative sign, sulphur or oxygen?   | 1                 |  |  |  |
| 3.  | Which xenon compound is isostructural with IC   | 14-?   | 1                 |  |  |  |
| 4.  | Which of the following compounds has a lone pair of electrons at the central atom? $H_2S_2O_8$ , $H_2S_2O_7$ , $H_2SO_3$ , $H_2SO_4$  |  |                   |  |  |  |
| 5.  | Complete the following reactions:  a) $(NH_4)_2Cr_2O_7$ heat $\rightarrow$ b) $\Gamma + O_3 + H_2O \rightarrow$ c) NaOH( hot and conc.) $+ Cl_2 \rightarrow$ d) $XeF_4 + O_2F_2$ (143K) $\rightarrow$ e) $Br_2 + F_2$ (excess) f) $PCl_3 + H_2O \rightarrow$ g) $XeF_2 + PF_5 \rightarrow$ h) $NaN_3 \rightarrow$ i) $F_{2(g)} + H_2O(l) \rightarrow$ j) $Ca_3P_2(s) + H_2O(l) \rightarrow$ | k) $P_4 + NaOH + H_2O \rightarrow$ l) $Cu + HNO_3(dil) - \rightarrow$ m) $P_4 + SO_2Cl_2 \rightarrow$ n) $Fe^{3+} + SO_2 + H_2O \rightarrow$ o) $XeF_6 + H_2O(excess) \rightarrow$ p) $C + H_2SO_4(conc.) \rightarrow$ q) $Cl_2 + F_2(excess) \rightarrow$ r) $AgCl(s) + NH_3(aq) \rightarrow$ s) $HgCl_2(aq) + PH_{3(g)} \rightarrow$ t) $PCl_5 + H_2O(excess) \rightarrow$ u) $Cu^{2+} + NH_3(excess)$ | 1<br>mark<br>each |  |  |  |
| 6.  | Give chemical reaction in support of the following observations.  a) Sulphuric acid has low volatility b) Iodide ions can be oxidized by oxygen in acidic medium  |  |                   |  |  |  |
| 7.  | <ul><li>a)Suggest a quantitative method for estimation of the sun.</li><li>b)Nitrogen oxides emitted from the exhaust sys deplete the concentration of ozone layer in upper</li></ul>   | tem of supersonic jet aeroplanes slowly  | 2                 |  |  |  |

|  | Draw the structures of the follows  | ing molecule   | es   |   |                                  | 1               |
|--|---|--|--|---|----------------------------------|-----------------|
|  | i. BrF <sub>3</sub>   | viii.  | XeF <sub>4</sub>   | XV.   | $N_2O_5$                         | maı             |
|  | ii. XeOF <sub>4</sub>   | ix.  | $O_3$  | xvi.  | HOClO <sub>2</sub>               | eac             |
|  | iii. $H_2S_2O_7$  | х.   | $\mathbf{S}_8$   | xvii.   | XeF <sub>6</sub>                 |                 |
|  | iv. Solid PCl <sub>5</sub>  | xi.  | NF <sub>3</sub>  | xviii.  | SF <sub>4</sub>                  |                 |
|  | $V. H_2S_2O_8$  | xii.   | PCl <sub>3</sub>   | xix.  | ClF <sub>3</sub>                 |                 |
|  | vi. H <sub>3</sub> PO <sub>2</sub><br>vii. H <sub>3</sub> PO <sub>3</sub>   | xiii.  | XeF <sub>2</sub><br>XeO <sub>3</sub>   | XX.   | BrF <sub>5</sub>                 |                 |
|  |   | xiv.   |  |   |                                  |                 |
|  |   |  |  |   |                                  |                 |
| ).   | Arrange the following in the order of property indicated for each set:  |  |  |   |                                  |                 |
|  | i) HF, HCl, HBr, HI -Increasing acid strength.  |  |  |   |                                  | mai             |
|  | ii) NH <sub>3</sub> , PH <sub>3</sub> , AsH <sub>3</sub> , SbH <sub>3</sub> , BiH <sub>3</sub> - Increasing reducing power.   |  |  |   |                                  | eac             |
|  | iii) HCl, HI, HBr, HF - Decreasing thermal stability.   |  |  |   |                                  |                 |
|  | iv) Xe, He, Kr, Rn, Ne - Decreasing order of electron gain enthalpy.  |  |  |   |                                  |                 |
|  | v)F <sub>2</sub> , Cl <sub>2</sub> , Br <sub>2</sub> , I <sub>2</sub> - Increasing bond dissociation enthalpy.  |  |  |   |                                  |                 |
| 0.   | Write balanced chemical equations for the following reactions:  |  |  |   |                                  | 1               |
| •  | _   |  |  | <b>3115.</b>  |                                  | ma              |
|  | <ul> <li>i) Reaction of Cl<sub>2</sub> with cold and dilute NaOH.</li> <li>ii) When phosphine is passed through Copper sulphate solution.</li> </ul>  |  |  |   |                                  |                 |
|  | iii) Chlorine reacts with hot concentrated solution of sodium hydroxide.  |  |  |   |                                  |                 |
|  | iv) Orthophosphorus acid is heated.   |  |  |   |                                  |                 |
|  | v) PtF <sub>6</sub> and Xenon are mixed together.   |  |  |   |                                  |                 |
| 1  | A   | :  | 1 D  | Th D :  |                                  | 2               |
| 1.   | An orange solid A on heating gives a colourless gas B. The gas B in dry condition is  |  |  |   |                                  |                 |
|  | passed over heated Ca to give a solid C. The solid C further reacts with water to produce gas D which forms a blue coloured compound E on reaction with copper sulphate   |  |  |   |                                  |                 |
|  |   |  |  |   | _                                |                 |
|  | gas D which forms a blue col  | oured comp   | oound E on   | reaction with   | copper sulphate                  |                 |
|  |   | oured comp   | oound E on   | reaction with   | copper sulphate                  |                 |
| 2.   | gas D which forms a blue col  | oured comp<br>give the seq   | oound E on uence of reac   | reaction with<br>tions involved   | copper sulphate                  | 1               |
| 2.   | gas D which forms a blue col solution. Identify A,B,C,D,E and   | oured comp<br>give the seq<br>be isoelectro  | oound E on uence of reaconic with ClO  | reaction with tions involved  | copper sulphate                  |                 |
| 2.   | gas D which forms a blue col solution. Identify A,B,C,D,E and a)Which neutral molecule would  | oured comp<br>give the seq<br>be isoelectrony be a stron   | oound E on uence of reaconic with ClOger oxidizing   | reaction with tions involved  | y?                               | 1<br>mar<br>eac |
| 2.   | gas D which forms a blue col<br>solution. Identify A,B,C,D,E and<br>a)Which neutral molecule would<br>b)Of Bi(V) and Sb (V) which ma  | oured comp<br>give the seq<br>be isoelectrony be a stron   | oound E on uence of reaconic with ClOger oxidizing   | reaction with tions involved  | y?                               | ma              |
| 2.   | gas D which forms a blue col solution. Identify A,B,C,D,E and a)Which neutral molecule would b)Of Bi(V) and Sb (V) which mac)Describe the favourable conditi  | oured comp<br>give the seq<br>be isoelectrony be a stron<br>ons for the r  | oound E on uence of reaconic with ClO ger oxidizing nanufacture o  | reaction with<br>tions involved<br>?<br>?<br>agent and wh<br>f sulphuric ac   | y? id by Contact                 | ma              |
| 2.   | gas D which forms a blue col solution. Identify A,B,C,D,E and a)Which neutral molecule would b)Of Bi(V) and Sb (V) which mac)Describe the favourable condition process.   | oured comp<br>give the seq<br>be isoelectrony be a stron<br>ons for the r  | oound E on uence of reaconic with ClO ger oxidizing nanufacture o  | reaction with<br>tions involved<br>?<br>?<br>agent and wh<br>f sulphuric ac   | y? id by Contact                 | ma              |
|  | gas D which forms a blue col solution. Identify A,B,C,D,E and a)Which neutral molecule would b)Of Bi(V) and Sb (V) which mac)Describe the favourable condition process. d)Mention the optimum condition process.  | oured comp<br>give the seq<br>be isoelectrony be a stron<br>ons for the r  | oound E on uence of reaconic with ClO ger oxidizing nanufacture o  | reaction with<br>tions involved<br>?<br>?<br>agent and wh<br>f sulphuric ac   | y? id by Contact                 | ma              |
| .3   | gas D which forms a blue col solution. Identify A,B,C,D,E and  a)Which neutral molecule would b)Of Bi(V) and Sb (V) which mac)Describe the favourable conditi process. d)Mention the optimum condition process.  Account for the following:   | oured comp<br>give the seq<br>be isoelectrony<br>be a strong<br>ons for the reasons for the incomp   | oound E on uence of reaconic with ClO ger oxidizing nanufacture o  | reaction with<br>tions involved<br>?<br>?<br>agent and wh<br>f sulphuric ac   | y? id by Contact                 | ma<br>eac       |
| 3  | gas D which forms a blue col solution. Identify A,B,C,D,E and a)Which neutral molecule would b)Of Bi(V) and Sb (V) which mac)Describe the favourable condition process.  d)Mention the optimum condition process.  Account for the following: Ammonia is a stronger base than   | be isoelectrony be a strong ons for the response of the incomplete       | oound E on uence of reaconic with ClO ger oxidizing nanufacture of lustrial manufacture  | reaction with<br>tions involved<br>?<br>?<br>agent and wh<br>f sulphuric ac   | y? id by Contact                 | ma<br>eac       |
| 3  | gas D which forms a blue col solution. Identify A,B,C,D,E and a)Which neutral molecule would b)Of Bi(V) and Sb (V) which mac)Describe the favourable conditi process. d)Mention the optimum condition process.  Account for the following: Ammonia is a stronger base than Bond angle in PH <sub>3</sub> molecule is less than and the solution of the solution of the solution of the solution.  | be isoelectrony be a strong ons for the response of the incomplete       | oound E on uence of reaconic with ClO ger oxidizing nanufacture of lustrial manufacture  | reaction with<br>tions involved<br>?<br>?<br>agent and wh<br>f sulphuric ac   | y? id by Contact                 | ma<br>eac       |
| 3  | gas D which forms a blue col solution. Identify A,B,C,D,E and  a)Which neutral molecule would b)Of Bi(V) and Sb (V) which may c)Describe the favourable condition process.  d)Mention the optimum condition process.  Account for the following: Ammonia is a stronger base than Bond angle in PH <sub>3</sub> molecule is lessolid PCl <sub>5</sub> is an ionic compound.  | oured comp<br>give the sequence be isoelectrony<br>be a strong ons for the real strong for the incomplete the sequence of the incomplete the sequence of the sequenc | oound E on uence of reaconic with ClO ger oxidizing nanufacture of lustrial manufacture  | reaction with<br>tions involved<br>?<br>?<br>agent and wh<br>f sulphuric ac   | y? id by Contact                 | ma<br>eac       |
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| 3<br>()<br>()<br>()<br>()<br>()<br>()<br>()  | gas D which forms a blue col solution. Identify A,B,C,D,E and  a)Which neutral molecule would b)Of Bi(V) and Sb (V) which mac)Describe the favourable condition process.  d)Mention the optimum condition process.  Account for the following:  Ammonia is a stronger base than Bond angle in PH <sub>3</sub> molecule is lessolid PCl <sub>5</sub> is an ionic compound. PCl <sub>5</sub> is known but NCl <sub>5</sub> is not known but NCl <sub></sub> | be isoelectrony be a strong one for the real phosphine.  The seed that the country is a strong one for the incomplete that the country is a strong one for the incomplete that the country is a strong one for the country is a strong of the       | oound E on uence of reaconic with ClO ger oxidizing nanufacture of dustrial manufacture of the NH <sub>3</sub> .   | reaction with tions involved.  -? agent and whe f sulphuric acture of amm     | y? id by Contact                 | ma<br>eac       |
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| l)<br>m)<br>n)<br>o)<br>p) | H <sub>3</sub> PO <sub>2</sub> acts as a monobasic acid. Sulphur vapour exhibits paramagnetic behavior. O <sub>3</sub> is more powerful oxidizing agent. Ozone is thermodynamically unstable. All bonds in PCl <sub>5</sub> are not equal in length. SF <sub>6</sub> is much less reactive than SF <sub>4</sub> . |      |  |  |  |
|----------------------------|---|------|--|--|--|
| m) n) o) p)                | O <sub>3</sub> is more powerful oxidizing agent. Ozone is thermodynamically unstable. All bonds in PCl <sub>5</sub> are not equal in length.  |      |  |  |  |
| n)<br>o)<br>p)             | Ozone is thermodynamically unstable. All bonds in PCl <sub>5</sub> are not equal in length.   |      |  |  |  |
| o)<br>p)                   | All bonds in PCl <sub>5</sub> are not equal in length.  |      |  |  |  |
| p)                         | <u> </u>  |      |  |  |  |
|                            |   |      |  |  |  |
| <b>q</b> )                 | $H_2S$ is less acidic than $H_2Te$ .  |      |  |  |  |
|                            | SF <sub>4</sub> is hydrolysed whereas SF <sub>6</sub> is not easily hydrolysed.   |      |  |  |  |
|                            |   |      |  |  |  |
|                            |   |      |  |  |  |
| 14.                        | Explain the following:  | 1    |  |  |  |
|                            |   | mark |  |  |  |
|                            |   | each |  |  |  |
|                            | Iron dissolves in HCl to form FeCl <sub>2</sub> and not FeCl <sub>3</sub> .   |      |  |  |  |
|                            | Fluorine is a stronger oxidizing agent than chlorine.   |      |  |  |  |
| c)                         | Fluorine does not exhibit any positive oxidation state  |      |  |  |  |
| d)                         | Noble gases are the least reactive elements.  |      |  |  |  |
|                            | XeF <sub>2</sub> has a linear shape and not a bent structure.   |      |  |  |  |
|                            | Amongst all noble gases only xenon is known to form compounds with oxygen and   |      |  |  |  |
|                            | fluorine.   |      |  |  |  |
| g)                         | Helium is used in diving equipment  |      |  |  |  |
|                            | No distinct chemical compound of helium is known.   |      |  |  |  |
| i) :                       | Most of the reactions of fluorine are exothermic  |      |  |  |  |
| j) '                       | The following order of increase in strength of acids: PH <sub>3</sub> < H <sub>2</sub> S < HCl  |      |  |  |  |
| k)                         | The oxidizing power of oxoacids of chlorine follows the order:  |      |  |  |  |
|                            | HClO <sub>4</sub> < HClO <sub>3</sub> < HClO <sub>2</sub> < HClO  |      |  |  |  |
| 1)                         | The acidic property of oxoacids of chlorine follows the order:  |      |  |  |  |
|                            | $HClO_4 > HClO_3 > HClO_2 > HClO$   |      |  |  |  |
| m)                         | In the structure of HNO <sub>3</sub> molecule, the N-O bond(121pm) is shorter than N-OH bond  |      |  |  |  |
|                            | (140pm)   |      |  |  |  |
| n)                         | In solution of H <sub>2</sub> SO <sub>4</sub> in water, the second dissociation constant Ka <sub>2</sub> , is less than the first   |      |  |  |  |
|                            | dissociation constant Ka <sub>1</sub>   |      |  |  |  |
| 0)                         | The pKa value for HOCl is higher than that of HClO <sub>2</sub>   |      |  |  |  |
| p)                         | . Inter halogen compounds are more reactive than halogens   |      |  |  |  |
|                            | The basic character among the hydrides of group 15 elements decreases with increasing   |      |  |  |  |
| -                          | atomic numbers  |      |  |  |  |
|                            |   |      |  |  |  |